Electronic Supplementary Material (ESI) for RSC Advances.

Supporting Information

Structural engineering of ultrathin BiOBr nanosheets for boosted photodegradation performance toward Rhodamine B

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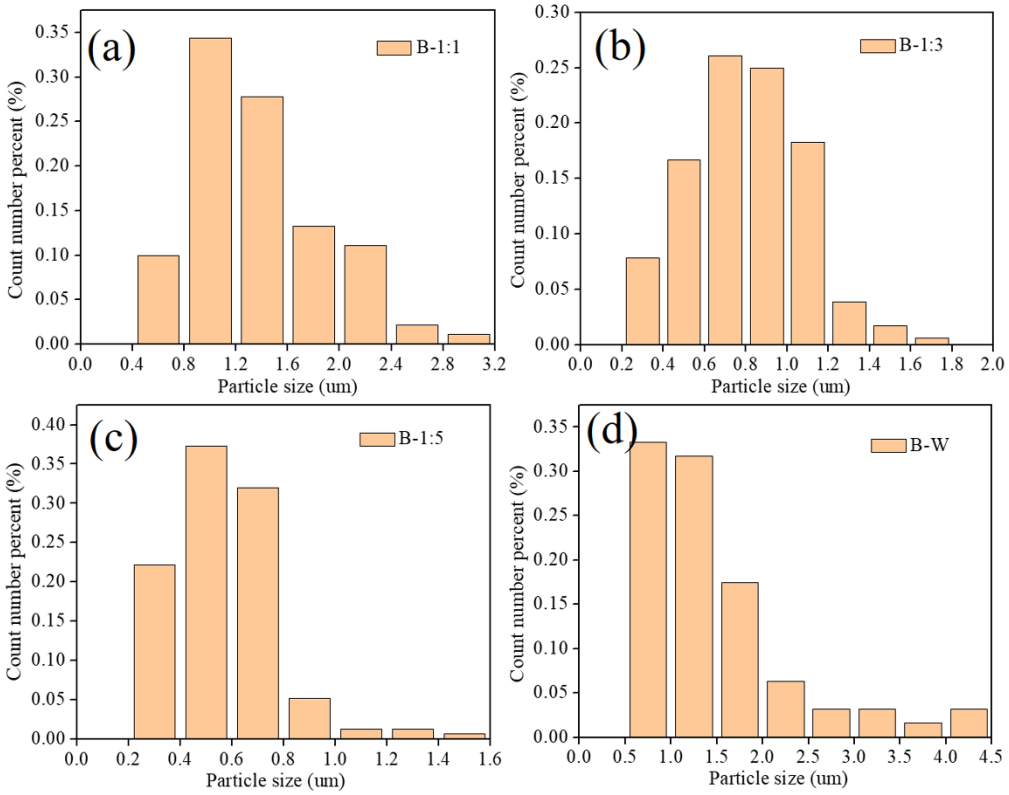

Fig. S1. The particle size distribution of the as-prepared BiOBr samples.

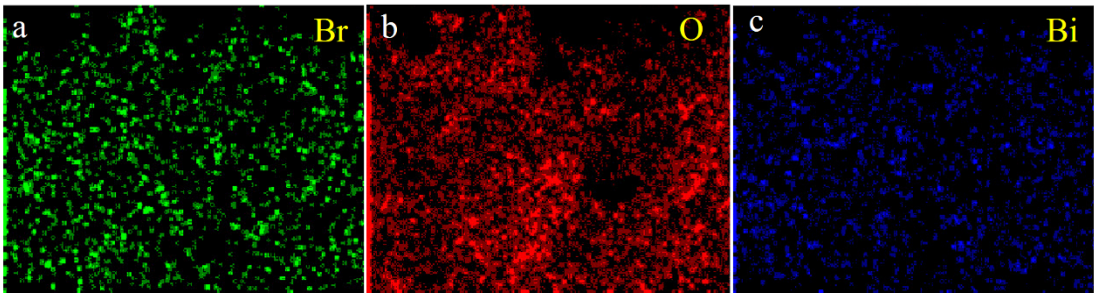

Fig. S2 EDS elemental mapping of different elements in B-1:3 sample.

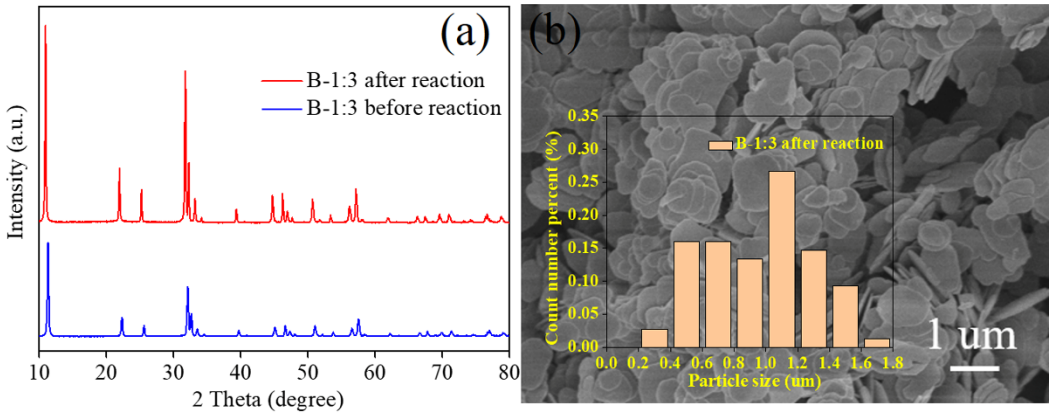

Fig. S3 The XRD patterns of B-1:3 before and after reaction (a), the SEM image (b) and particle size distribution (inserted in Fig. S3b) of B-1:3 after reaction.

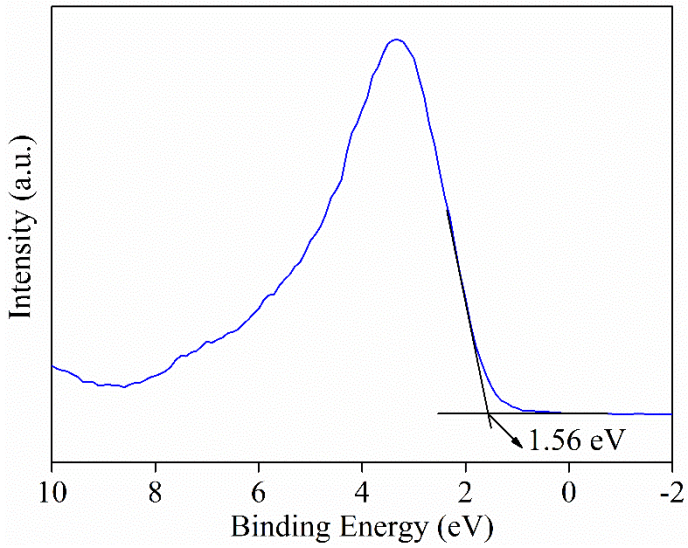

Fig. S4 The valence band XPS spectrum for B-1:3.

Table S1 The photoactivity comparisons toward RhB about BiOBr and BiOBr-based photocatalysts

Catalysts	Light source	Concentration (mg/L)	Volume (mL)	Quality (mg)	Irradiation time (min)	Degradation rate (%)	Ref.
7%$BiSbO_4$/	Visible	10	100	30	45	96	[1]

BiOBr	light						
BiOBr/BiO$Ac_{1-0.8}Br_{0.8}$	Visible light	20	50	20	120	99.4	[2]
$BiOBr_xI_{1-x}$/BiOBr	Visible light	20	100	50	120	80	[3]
BiOBr/$Bi_{24}O_{31}Br_{10}$	Visible light	10	100	50	60	92.4	[4]
Bi@BiOBr	Visible light	10	50	10	120	98.2	[5]
S-doped BiOBr	Visible light	20	100	50	50	100	[6]
BiOBr	Visible light	20	100	40	30	97	This work

References

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